Remove

Party of Interest under 35 U.S.C. 118

Active US Military Service

Suffix

Family Name

JUFFERMANS

Non US Residency

ΒE

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Application Data Sheet 37 CFR			7 CED	R 1 76 Attorney Docket Number			umber	NL031520			
Appi	ication Da	CIK	1.70	Applica	ation N	Numbe	r				
Title o	of Invention	LITHOGRAF	PHY SYS	TEM U	SING A PI	ROGR	AMMA	BLE ELE	CTRO-\	WETTING MASK	
bibliogra This do	aphic data arran cument may be	ged in a format s	pecified bitronically	y the Un and sub	ited States mitted to th	Patent	and Tra	idemark O	ffice as o	Ibmitted. The following form contains outlined in 37 CFR 1.76. ng the Electronic Filing System (EFS	
		r 37 CFR									
										all under a Secrecy Order pur not be filed electronically.)	suant to
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Applic	cant Authori	ty • Inventor	○Le	gal Rep	resentativ	e und	er 35 l	J.S.C. 11	7	Party of Interest under 35 U.S.	.C. 118
Prefix	Given Nar	ne		Middle Name					Fami	ily Name	Suffix
Peter									DIRK	SEN	
Resid	dence Inforn	nation (Selec	t One)	US Residency Non US Residency Active US Military Service							
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Mailin	ng Address o	of Applicant:									
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Prefix	1		1	Middle Name					Fami	ily Name	Suffix
	Robert			Andrew					HAYES		
Resid		nation (Selec	t One)		Residenc	; у (No	n US Res			<u> </u>
City	Eindhoven	`		Count	try Of Re	esider	ncei	NL			
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OLegal Representative under 35 U.S.C. 117

Middle Name

US Residency

Anthonius Henricus

Country Of Residencei

EFS Web 1.0

City

Prefix

Applicant 3

Applicant Authority • Inventor

Residence Information (Select One)

Given Name

Casparus

Leuven

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Application Data Sheet 37 CFR				CFR 1.7	.76 Attorney Docke					520				
						Application Number								
Title of Invention LITHOGRAPHY SYSTE						TEM USING A PROGRAMMABLE ELECTRO-WETTING MASK								
Citizenship under 37 CFR 1.41(b) i					b) i NL									
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Prefix	Given Nan		I_		Mi	ddle Na	me		Family		y Name			Suffix
	Thomas									STEFF	EN			
Reside	ence Inform	ation (S	Select (One)	US	Residenc	;у (No	n US Res	sidency	Active	US Mili	tary Servi	ce
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Email /	Address		jeanne	e.rusciano@philips.com							Add Em	nail	Remov	/e Email
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Title of	f the Invent	ion	LITHO	DGRAPHY	SY	STEM US	SING A	PROG	RAMMA	BLE ELE	CTRO-WET	TING M	IASK	
Attorney Docket Number NL031520			1520	Small Entity Status Claimed										
Application Type Nonprov			Nonprovisional											
Subject Matter Utility														
Sugge	sted Class	(if any)						S	Sub Class (if any)					
Sugge	sted Techn	ology C	enter (i	if any)							1			
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Application Dat	a She	et 37 CFR 1 76	Attorney Docket Number NL031			520				
Application But	u 0110	.0.07 01 10 11.70	Applicati	on Number						
Title of Invention LITHOGRAPHY SYSTEM USING A PROGRAMMABLE ELECTRO-WETTING MASK										
Publication Information:										
Request Early Publication (Fee required at time of Request 37 CFR 1.219)										
Request Not to Publish. I hereby request that the attached application not be published under 35 U.S.C. 122(b) and certify that the invention disclosed in the attached application has not been and will not be the subject of an application filed in another country, or under a multilateral agreement, that requires publication at eighteen months after filing.										
Representative Information: Representative information should be provided for all practitioners having a power of attorney in the application. Providing this information in the Application Data Sheet does not constitute a power of attorney in the application (see 37 CFR 1.32).										
Enter either Cust	omer	Number or comple Number will be used for	ete the	Representative N	lame section	n below.	If both sections			
Please Select One:	(Customer Number	01	JS Patent Practitione	er Us	S Representat	ive (37 CFR 11.9)			
Customer Number		24737			1.					
Domestic Priority Information: This section allows for the applicant to claim benefit under 35 U.S.C. 119(e), 120, 121, or 365(c). Providing this information in the application data sheet constitutes the specific reference required by 35 U.S.C. 119(e) or 120, and 37 CFR 1.78(a)(2) or CFR 1.78(a) (4), and need not otherwise be made part of the specification.										
Prior Application	Status					Ren	nove			
Application Num	ber	Continuity ⁻	Гуре	Prior Applicati	on Number	Filing Da	te (YYYY-MM-DD)			
Additional Domestic the Add button.	Priori	 ty Data may be gen	erated wit	hin this form by s	electing	A	dd			
Foreign Priorit	y Inf	ormation:								
This section allows for the applicant to claim benefit of foreign priority and to identify any prior foreign application for which priority is not claimed. Providing this information in the application data sheet constitutes the claim for priority as required by 35 U.S.C. 119(b) and 37 CFR 1.55(a).										
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Application Num	per	Country	/ ' 	Parent Filing D	ate (YYYY-l	-	Priority Claimed			
03104914.1 EP 2003-12-22 • Yes No										
Additional Foreign Priority Data may be generated within this form by selecting the Add button.										
Assignee Information:										
Providing this information in the application data sheet does not substitute for compliance with any requirement of part 3 of Title 37 of the CFR to have an assignment recorded in the Office.										
Assignee 1 Remove										
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Application Da	ta Sha	eet 37 CFR 1.76	Attorney Docket Number	NL031520							
Application ba	ita Siit	et 37 CH (1.70	Application Number								
Title of Invention	LITHC	GRAPHY SYSTEM US	ING A PROGRAMMABLE ELECTRO-WETTING MASK								
Organization Name	e K	ONINKLIJKE PHILIPS	ELECTRONIC. N.V.	ECTRONIC N.V.							
Mailing Address I			,								
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Address 2											
City		EINDHOVEN	State/Prov	vince							
Country NL			Postal Cod	de 5621 BA							
Phone Number			Fax Number								
Email Address			1	-							
Additional Assignee Data may be generated within this form by selecting the Add											

Signature:

button.

A signature of the applicant or representative is required in accordance with 37 CFR 1.33 and 10.18. Please see 37 CFR 1.4(d) for the form of the signature.									
Signature	/Michael E. Marion/		Date (YYYY-MM-DD) 2006-06-19						
First Name	Michael E.	Last Name	Marion	Registration Number	32,266				

This collection of information is required by 37 CFR 1.76. The information is required to obtain or retain a benefit by the public which is to file (and by the USPTO to process) an application. Confidentiality is governed by 35 U.S.C. 122 and 37 CFR 1.14. This collection is estimated to take 23 minutes to complete, including gathering, preparing, and submitting the completed application data sheet form to the USPTO. Time will vary depending upon the individual case. Any comments on the amount of time you require to complete this form and/or suggestions for reducing this burden, should be sent to the Chief Information Officer, U.S. Patent and Trademark Office, U.S. Department of Commerce, P.O. Box 1450, Alexandria, VA 22313-1450. DO NOT SEND FEES OR COMPLETED FORMS TO THIS ADDRESS. **SEND TO: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.**

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- 3. A record in this system of records may be disclosed, as a routine use, to a Member of Congress submitting a request involving an individual, to whom the record pertains, when the individual has requested assistance from the Member with respect to the subject matter of the record.
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- 6. A record in this system of records may be disclosed, as a routine use, to another federal agency for purposes of National Security review (35 U.S.C. 181) and for review pursuant to the Atomic Energy Act (42 U.S.C. 218(c)).
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- A record from this system of records may be disclosed, as a routine use, to a Federal, State, or local law enforcement agency, if the USPTO becomes aware of a violation or potential violation of law or regulation.